

Electronic Acknowledgement Receipt

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Confirmation Number:	3280
Title of Invention:	Positive-type resist composition for liquid immersion lithography and method for forming resist pattern
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)/ Message Digest	Multi Part /.zip	Pages (if appl.)
1	Transmittal Letter	Information_Disclosure_State ment.pdf	54482 d361c8d3fb6c891783f4e864bbca4394c33 d4fdf	no	2

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2	Information Disclosure Statement (IDS) Filed (SB/08)	US_IDS_Form__SB_08a.pdf	776417 9dd9f80748003a728cdf7420b4e6e13ed4dd4c28	no	4
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3	NPL Documents	Notice_of_Reasons_for_Rejection.pdf	107068 4f8bceca4768ac1d61815b417d2460f4f759f5cee	no	3
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